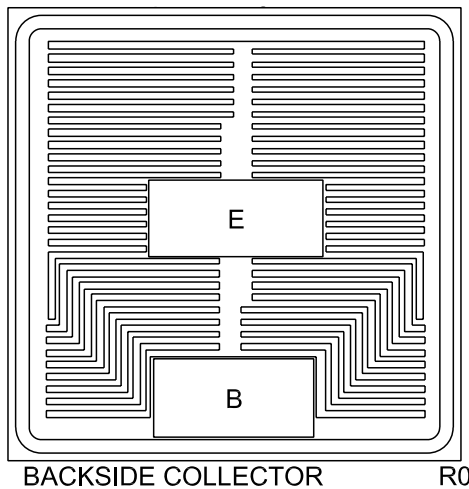


**PROCESS DETAILS**

Die Size	167 x 167 MILS
Die Thickness	9.5 MILS
Base Bonding Pad Area	59 x 29 MILS
Emitter Bonding Pad Area	64 x 28 MILS
Top Side Metalization	Al - 45,000Å
Back Side Metalization	Ti/Ni/Ag - 3,000Å, 10,000Å, 10,000Å

**GEOMETRY**



**GROSS DIE PER 5 INCH WAFER**

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**PRINCIPAL DEVICE TYPES**

MJE13009

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R0 (5- January 2006)